

Laser-Based Sample Preparation

Preparing TEM Specimens and Atom Probe Tips by Laser Machining

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Introduction

Over the past fifty years, lasers have found many applications in science and technology. The most important features of lasers are that photons are inherently free of elemental contamination, extremely high-energy

densities can be focused to small diameters, and the laser beam can be precisely positioned using deflection mirrors. By reducing pulse lengths from a few nanoseconds down to the picosecond or femtosecond range, superficial surface heat damage from ablation can be reduced to depths of a few microns or less. Available for many decades, lasers have become extremely reliable processing tools in many areas, including the automotive industry (welding, drilling, and measuring), thin-film processing (scribing, patterning), and even esthetic surgery (dermabrasive ablation, LASIK).

In view of the outstanding characteristics of lasers as tools for micro machining, it is surprising that instruments for specimen preparation, for state-of-the-art analytical techniques, have not made use of laser technology. 3D-Micromac company has developed a dedicated laser micromachining instrument for specimen preparation. The name of this instrument indicates its purpose: microPREP (microscopy preparation).

At sufficiently high power (or more precisely fluence), laser radiation is able to ablate all kinds of materials. Using ultra-short pulses and high pulse energies, ablation-based tools can also process materials that are transparent to the laser's wavelength. The ablation rate of laser micromachining is about six orders of magnitude larger than that of the Ga-ion beam used in focused ion beam (FIB) workstations, and it is even about four orders of magnitude higher than the milling rate of the Xe-plasma-FIB. Moreover, lasers can be very precisely positioned on a given workpiece and straightforwardly focused using standard optical

elements. Since laser radiation consists just of photons (rather than an ion beam, which may have unwanted implantation effects), laser micro-machining is clean in terms of contamination. This whitepaper shows how this technology can be used to produce thin lamellae for transmission electron microscopy (TEM) and sharp tips for atom probe tomography (APT).

Tasks for the laser

Specimen preparation techniques need to be fast, reliable, cost-effective, and artifact-free on the micrometer scale or smaller. Traditional mechanical specimen preparation and FIB systems currently dominate the field. While the former is accompanied by the high costs of timeconsuming processes, the latter is characterized by the high costs of instrument ownership.

There are a number of specific capabilities of a laser-based thin-specimen preparation tool. Based on several patents, the tool described here has a range of basic functionalities, including laser cutting from the bulk, followed by local laser thinning in an almost entirely automated fashion. Making use of a rugged, ultra-short-pulsed laser source, the process is characterized by low running costs, suitability for all materials of modern microelectronics, freedom from contamination, and a precision of about one micrometer.

Instrumental setup and performance

The main components of the microPREP™ PRO instrument are a 532 nm laser source with 3 W average power and an objective lens focusing the laser beam to a small probe (beam diameter ~10 μm). The pulse energy of up to 60 μJ enables high ablation rates compared with a broad Ar⁺ ion beam or the focused Ga⁺ or Xe⁺ ion beams used in FIB instruments. Figure 1 shows a (300 × 300 × 250) μm³ box milled by using the microPREP™ PRO. This specific preparation was done in less than 5 min. If a FIB were used for the same task, it would take up to 17 days. Thus the removal of bulk material can be efficiently done by means of this laser instrument, but the speed still depends on the dimensions, the task, and the specific material to be removed.

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Heat-Affected Zone

Widespread use of laser micromachining for the preparation of thin TEM specimens has been hampered by concerns regarding thermal damage to the sample. It is important to note that this effect can be controlled and minimized, depending on the material and the analysis task. The formation of a melt takes place when traditional pulsed laser (not ultra-short-pulsed) radiation interacts with matter and expels material from the location of machining. This heating is caused by the electromagnetic wave from the laser, which excites phonons and leads to a local increase in temperature.

For ultra-short pulsed lasers, however, the excitation is absorbed by the electronic system of the material, leading to much reduced heating effects. Ablation is not entirely “athermic,” but it was found to be restricted to a depth of less than 0.4 μm for silicon. The extent of this heat-affected zone (HAZ) can become larger when basic principles of laser micromachining are not obeyed, for example, when the feed rate is too slow. Nevertheless, there is still a layer of material, micrometers in extent (worst case), which will sustain some structural damage. This structural damage strongly depends on the given material and the laser parameters

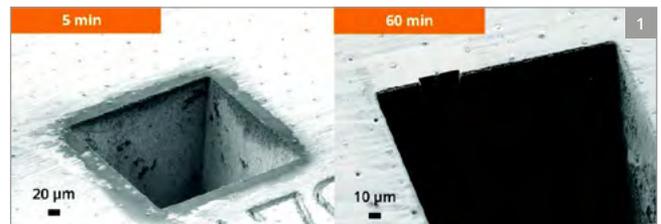


Figure 1: Boxmilling. (left) A Si sample ($300 \times 300 \times 250 \mu\text{m}^3$) machined by microPREP in 5 minutes. (right) Excavated through silicon via (TSV) in the box prepared by the microPREP™ and finished using a Zeiss Auriga 40 FIB.

used. To keep structural damage small and under control, the ablation process is restricted to a highly localized area. The HAZ is entirely removed by the FIB process. Depending on the material, the specific specimen, and the FIB parameters themselves, it can take few seconds to few minutes to remove the HAZ.

Workflows

Different workflows have been developed for processing bulk samples, cross sections, tomography, atomprobe pillars, and samples for micromechanical testing. Specimens for TEM and APT generally have starting dimensions of 1–3 mm. The workflow for cross-section preparation in the “XLChunk” mode is described below and shown in Figure 2.

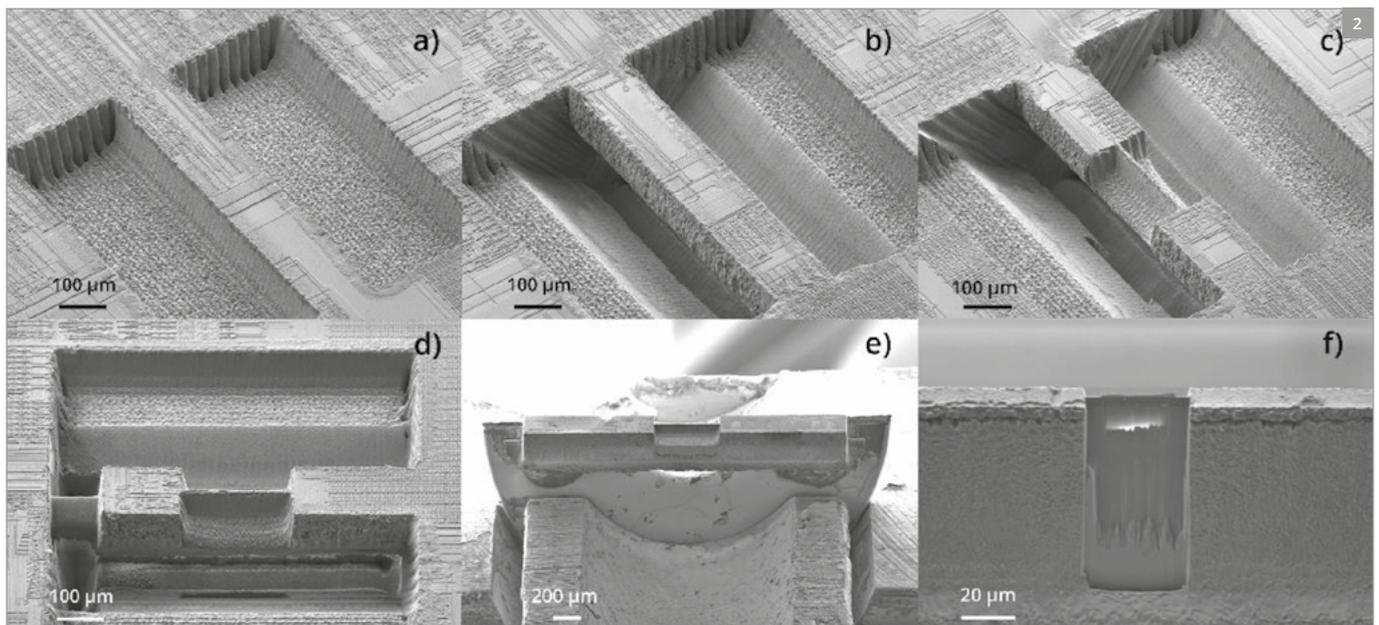


Figure 2: Workflow for cross-section preparation in the XL-Chunk mode. (a) Laser milling of two side-boxes, which are required for the second step and for ease in handling with tweezers. (b) Laser milling of trenches/undercut, which will allow freeing the sample from the rest of the bulk material. (c) Laser cutting or milling of the required structures (H-bar, or pillars/tips). (d) Laser cutting of support structures. (e) SEM micrograph of the laser-machined XL-Chunk with local thinned area glued to a half-ring. (f) SEM micrograph of a structure in silicon after local thinning (post-processing) with the laser and a FIB. (a–d) were taken by the microPREP™ overview camera. (e–f) were taken with the SEM of a Zeiss Auriga 40.

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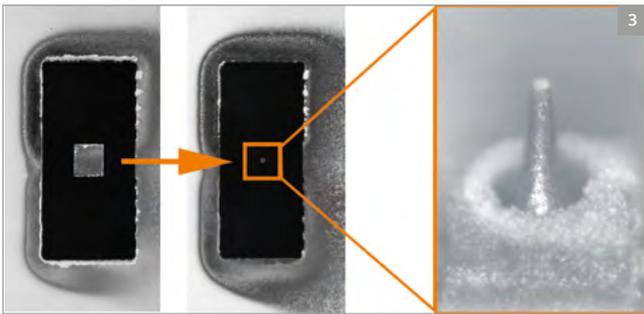


Figure 3: APT pillar preparation in silicon based on the XL-Chunk workflow. The pictures were taken by the microPREP™ overview camera.

The following cross-section workflow, based on the XLChunk approach, consists of five steps: (1) Laser milling of trenches/ undercut, which will allow freeing the sample from the rest of the bulk material. (2) Laser cutting or milling of the required structures (H-bar, or pillars/tips). (3) Laser cutting of support structures. (4) Removal of workpiece and gluing to a copper half-ring. (5) Post-processing with an Ar⁺ ion broad beam or with a focused Ga⁺ or Xe⁺ ion beam to remove structural damage in the HAZ.

This XL-Chunk workflow can be applied for TEM lamellae. Atom probe pillars can be prepared in two ways. One approach of a direct preparation of the pillar/tip on top of the XL-Chunk is shown in Figure 3. This illustrates that ultra-short-pulsed lasers are capable of fabricating tiny pillars in an automated fashion, which can be used as mounts or basic structures for APT.

Figure 4 shows a variety of forms and tasks that have been produced with this instrument for different methods of analysis. Another feature is the capability to upload CAD files. With this feature, regions of interest can be investigated by means of computer-aided navigation on the specimen, which is especially useful for semiconductor devices. Most tasks to be accomplished in this way involve quality assurance, failure analysis, or random sampling.

Cleaning

The aforementioned steps 1–5 for XL-Chunk preparation are done under ambient conditions without vacuum or inert gas atmosphere. Nevertheless, for the best results in terms of specimen cleanliness and an optimal start for post-processing steps, the instrument can be fitted with a contactless cleaning

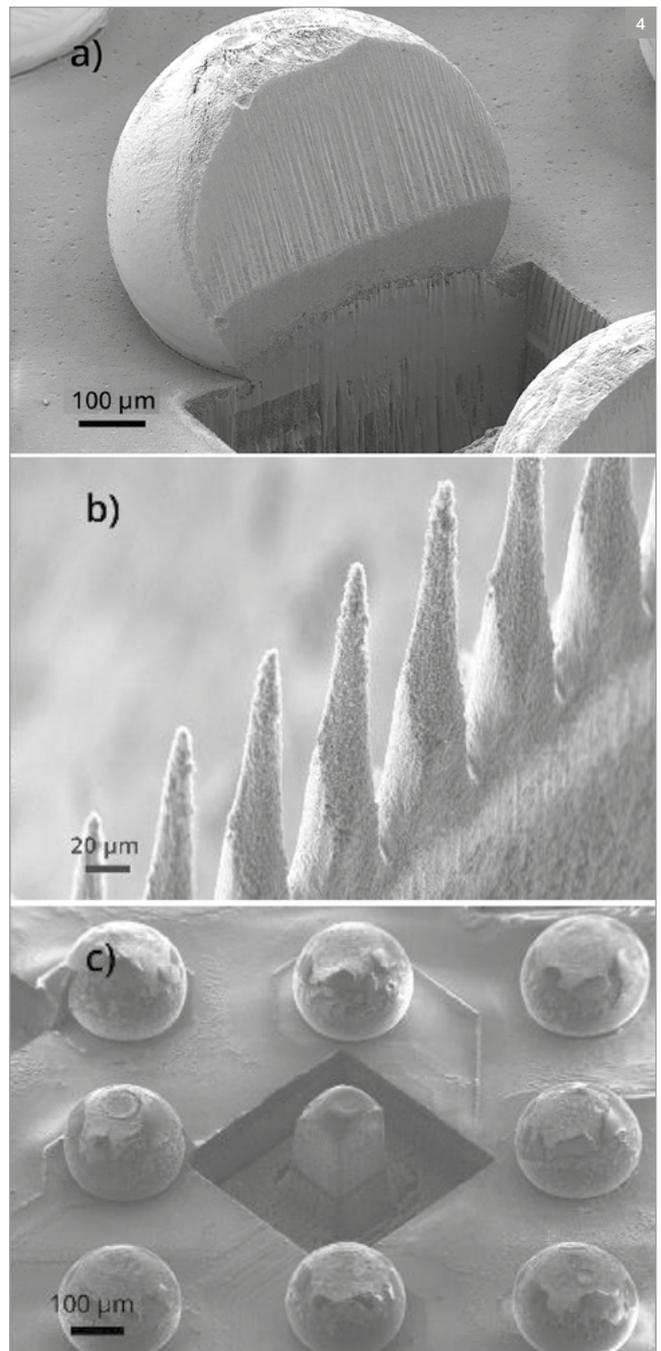


Figure 4: Examples of different preparation tasks showing the free form capability of the microPREP™. (4a) Bump of lead-free solder SAC 305. (4b) Silicon APT samples. (4c) Ball grid array of lead-free solder SAC 305 bumps. SEM images taken with Carl Zeiss Supra55VP.

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system called CO₂ Snow Jet. This comprises a source of liquid CO₂, a pressure reducer, a gas flow control unit, and a cleaning nozzle. After each processing step it is possible to add a cleaning step. The CO₂ is inert to the specimen and can be applied without concerns regarding contamination or unwanted implantation effects. Figure 5 shows a specimen before and after snow jetting. The debris is broadly removed without interfering with the specimen.

Flexibility

The laser is a high-energy light with a final beam diameter of about 10 µm, which is directed by a precise laser scanner. The sample is held by a precise stage system (up to 6 axes), in order to position the region of interest in the center of the scan field. Thus, sample geometries like tips, bars, or other geometrical patterns can be machined from almost any type of material. Electron transparent sections can be made at one position or at multiple positions. In addition, multiple workflows allow the preparation of samples at several different, pre-determined positions, enabling automated high-throughput sample preparation. This mode is particularly valuable for metrology, evaluation of homogeneity, and screening applications.

Laser micromachining of H-bars in IC-structures

An XL-chunk was prepared from an IC-structure while keeping supporting structures in place until the workpiece was removed with tweezers. In order to observe the structure in a TEM, the thinned region was glued to a 3 mm copper half-ring (Figure 2e). In the next step, a FIB system was used to remove the HAZ and to thin the sample to the required thickness of < 100 nm (Figure 2f). The effectiveness of the instrument can be shown by milling a box (300 × 300 × 250) µm³ in silicon material within 5 minutes and the post-processing with a FIB (Figure 1). Figure 4 shows different preparation tasks and some free-form capabilities. Figure 5 shows the contactless nonabrasive cleaning using the CO₂ Snow Jet.

Discussion and Conclusions

The XL-Chunk design is a support structure to hold TEM lamellae or atom probe tips. For APT, it is also possible to prepare several tips, as a line or an array of tips. It is also possible to mill complete APT cards. Modular design and flexible software allow the integration of this new type of chunk specimen prep into other

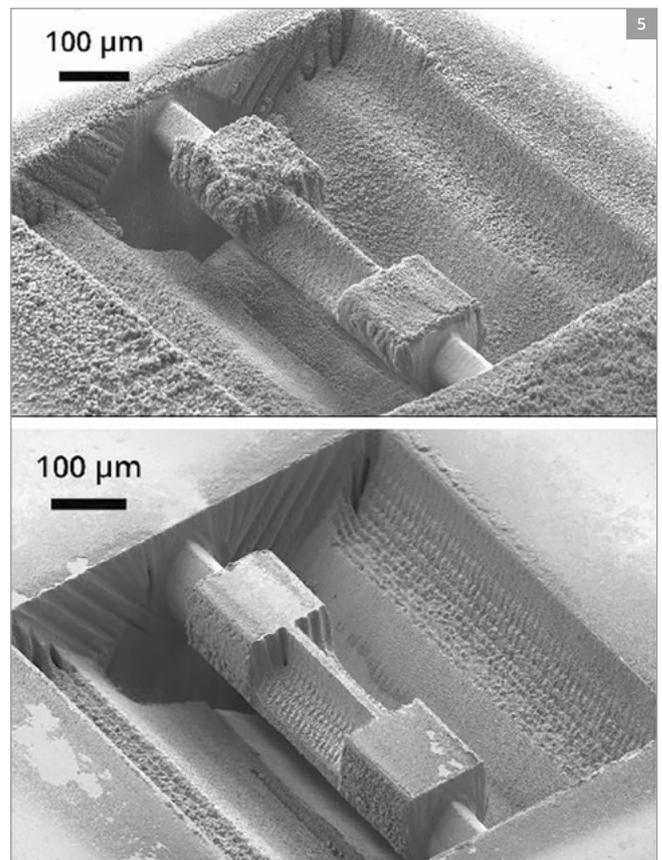


Fig. 5: Specimen cleaning. (top) Specimen after laser processing without cleaning. (bottom) Specimen after processing and cleaning with CO₂ Snow Jet. This specimen was machined by microPREP™ only, without additional FIB polishing.

workflows. Laser processing is an effective method for rapidly removing significant volumes of material to reduce the total time to a finished specimen. Since CO₂ cleaning is nonabrasive, it is a useful process for removing redeposited material. Further developments are ongoing to reduce the HAZ and also to expose samples to a defined micro-environment (inert gas or vacuum) to minimize oxidation.

A new ultra-short-pulsed laser-based thin specimen preparation system provides fast, cost-effective, and site-specific preparation of samples for microstructure evaluation. The microPREP™ PRO is not just a tool to prepare thin samples for TEM, it also can prepare specimens for APT and micromechanical testing. The modular stage and software design of the microPREP™ PRO laser tool meets the exacting requirements of several industries.